

Entered in Part  
RPL 2/24/05

RESPONSE TO NOTICE OF ALLOWANCE  
S/N 09/905,513  
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IN THE CLAIMS

Please amend the following claims as indicated:

1. (Previously Presented) Apparatus for electro-chemical deposition on a substrate, comprising:
  - an annular contact ring;
  - one or more electrical contact pads disposed on the contact ring;
  - a first seal disposed inward of the electrical contact pad and providing a seal with the contact ring;
  - a thrust plate adapted to move axially relative to the contact ring;
  - a second seal coupled to a side of the thrust plate facing the contact ring; and wherein the first seal further comprises:
    - a base disposed in a groove at least partially formed in the contact ring; and
    - a lip extending from the base and flaring radially outward towards the contact pads, the lip having at least one sealing surface.
2. (Cancelled)
3. (Previously Presented) The apparatus of claim 1, wherein the lip further comprises:
  - a first sealing surface adapted to seal with the substrate; and
  - a second sealing surface adapted to seal with the contact ring.
4. (Original) The apparatus of claim 1, wherein the contact ring further comprises:
  - a first surface;
  - a shoulder coupled to the first surface;